

## PREPARATION AND INVESTIGATION OF MEH-PPV FILMS USED FOR WHITE LIGHT EMITTING DIODES

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**Abstract.** *With the aim to prepare white Light Emitting Diode (WLED), the conjugate polymer films like (Poly[2-methoxy-5-(2'-ethyl-hexyloxy)-1,4-phenylene vinylene] (MEH-PPV) were investigated. Spectroscopic (absorption and emission) spectra of the MEH-PPV films showed that this polymer is suitable for casting onto the chips of the blue InGaN LED to make WLED. The luminous flux measured on the WLEDs in the integrating sphere proved that the white light emission can be obtained from the combination of inorganic LED and conjugate (MEH-PPV) polymers with an optimal thickness and a high quality. The aging process of MEH-PPV films was found to be strongly dependent post-treatment conditions. Reasonable heat treatment condition for the MEH-PPV polymers was suggested as in vacuum of  $5 \times 10^{-2}$  Pa at a temperature of  $120^\circ\text{C}$  in , for 2 hours.*

### I. INTRODUCTION

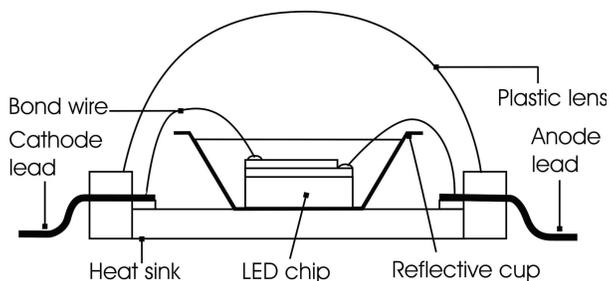
Research and applications of solid state lighting have grown exponentially in the world since the discovery of InGaN fabrication process by Nakamura [1]. The rapid development of white light-emitting diodes (WLED) over the last few years has opened new opportunities in the general illumination market [2,3]. The efficiency of commercialized WLEDs is now around 80 lm/W, which is comparable with that of fluorescent lamps. There are several approaches to fabricate white light LED, for instance by using a blue or UV LED to excite some phosphors to give white light [4]. The ability to obtain different color correlated temperature (CCT) and high color rendering index (CRI) of WLED gives new features to this kind of light sources [2]. The other attempt can be considered, using conjugate polymers like Poly[2-methoxy-5-(2'-ethyl-hexyloxy)-1,4-phenylene vinylene] (MEH-PPV) to be covered onto a blue LED chip. It is known that MEH-PPV has the absorption peak at ca. 480 nm and emits yellow light with wavelength of ca. 580 nm [5], one can expect that under excitation of light of the inorganic LED with wavelength around 480 nm, the blue-yellow combination light going out from the LED and MEH-PPV would be white light.

The aim of this work is to characterize properties of the MEH-PPV and the luminous flux of WLED made by covering the MEH-PPV layers onto blue LED chips. The color coordinates of WLED light was presented.

## II. EXPERIMENTAL

To characterize photoluminescent behavior of MEH-PPV films, we used a spin-coating technique for depositing the films onto glass substrates. The substrates were ultrasonically cleaned in distilled water, followed by cleaning in ethanol and acetone. To deposit the polymer films onto glass, MEH-PPV solutions were prepared by dissolving MEH-PPV powder (produce of Alphadrich Ltd.) in xylene with a ratio of 10 mg of MEH-PPV in 1 ml of xylene. The conditions for spin-coating are as follows: a delay time of 120 s, a rest time of 30 s, a spin speed of 1500 to 3000 rpm, an acceleration of 500 rpm and finally a drying time of 2 min. The thickness of the polymer layers was controlled by both the spin speed and solution content, the most suitable thickness for the absorption and photoluminescence characterization was found to be of 200 nm, corresponding to a spin speed of 2400 rpm. All the samples were put in a fore vacuum box until the measurements.

The blue InGaN based LED chip used in our experiment was made by OptoGaN Group (Germany). The LED structure consists of a 30-nm-thick GaN buffer layer grown on 100  $\mu\text{m}$ -thick sapphire substrate, a 1.5  $\mu\text{m}$ -thick layer of undoped GaN, a 4.5  $\mu\text{m}$ -thick layer of n-type GaN:Si, multiple quantum well (MQW) active layer, a 20 nm-thick p-type  $\text{Al}_{0.2}\text{Ga}_{0.8}\text{N}:\text{Mg}$  layer and a 0.2- $\mu\text{m}$ -thick p-type GaN:Mg layer. The MQW active layer of the blue LED consists of six 3-nm-thick undoped  $\text{In}_{0.3}\text{Ga}_{0.7}\text{N}$  well layers separated by 25 nm-thick undoped GaN barrier layers. The peak wavelength of this blue LED is 460 nm [2]. The purchased wafer was cut into individual dies, delivered on medium tack blue tape.



**Fig. 1.** Schematic illustration of the white LED structure. Basically a LED consists of four main components such as head sink, reflective cup, LED chip and plastic lens.

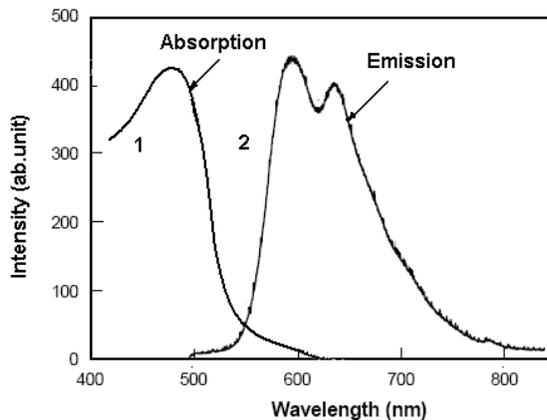
We use 1 W power blue LED for the study, with the die size around 1100  $\mu\text{m}$  x 1100  $\mu\text{m}$  (Fig. 1). The die was then bonded on the heat sink using silver epoxy glue. The quality of thermal resistance between the LED die and the substrate determined the working temperature of the LED chip. The gold wires was bonded on electrode pads by using digital thermosonic multipurpose wire bonder model 626. Four gold wires (diameter 20  $\mu\text{m}$ ) are used for power LED in order to increase the heat dissipation. In difference from spin-coating MEH-PPV samples for the spectroscopic characterization, to make WLEDs, MEH-PPV solution with a larger concentration of polymer was prepared, then casted onto the surface area between the top of the LED chip and the lens (see Fig. 1). For casting

the MEH-PPV layers, the pure MEH-PPV powder was dissolved in xylene with a ratio of 30 mg of MEH-PPV in 1 ml of xylene. After casting, the samples were annealed at 120 °C for 2 hours both in air and in vacuum. The thickness of MEH-PPV films was controlled by the dilution content and the number of casting cycles, it was in the range from 200 nm to 1000 nm. The electrical power used for lighting WLEDs was a DC current ranging from 1 to 350 mA.

The absorption spectra were carried out on a Jasco UV-VIS-NIR V570. Photoluminescence (PL) spectra were carried-out by using a high resolution spectrometer Model Microspec-235b. The luminous flux of the WLED was measured by using a PMS-50 (PLUS) UV-VIS-NIR spectrophotometer.

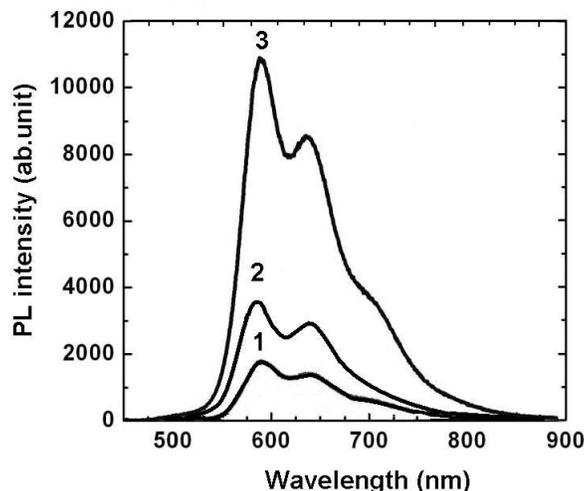
### III. RESULTS AND DISCUSSION

The absorption and photoluminescence spectra of MEH-PPV film were plotted in Fig 2. From this figure one can see that the MEH-PPV film has an absorption peak at 480 nm and two emission peaks at 570 nm and 640 nm. This is consistent with the reporting results on MEH-PPV films deposited by spin-coating for preparation of OLED [6]. Thus a blue LED chip can be used for exciting luminescence of the MEH-PPV film.



**Fig. 2.** Absorption (1) and emission (2) spectra of the MEH-PPV film. The thickness  $d = 200$  nm.

Fig. 3 presents plots of the PL spectra of MEH-PPV films with different film thickness and under an excitation of laser beam of 442 nm. All the PL spectra for the MEH-PPV films have two broad peaks respectively at 590 nm and 645 nm. The peak observed at 590 nm is much larger than the one at 645 nm, similarly to the electroluminescence spectra plotted in [7]. This shows that the commercial MEH-PPV polymer exhibits a large color range from yellow to red. Moreover, the intensity of the PL spectra is strongly dependent on the thickness of the spin-coated films. Approximately, the ratio of the intensities of PL spectra of the samples having thicknesses of 200, 400 and 1000 nm is of 1:2:6. This result demonstrated that the thicker films the larger PL intensity was obtained. However,

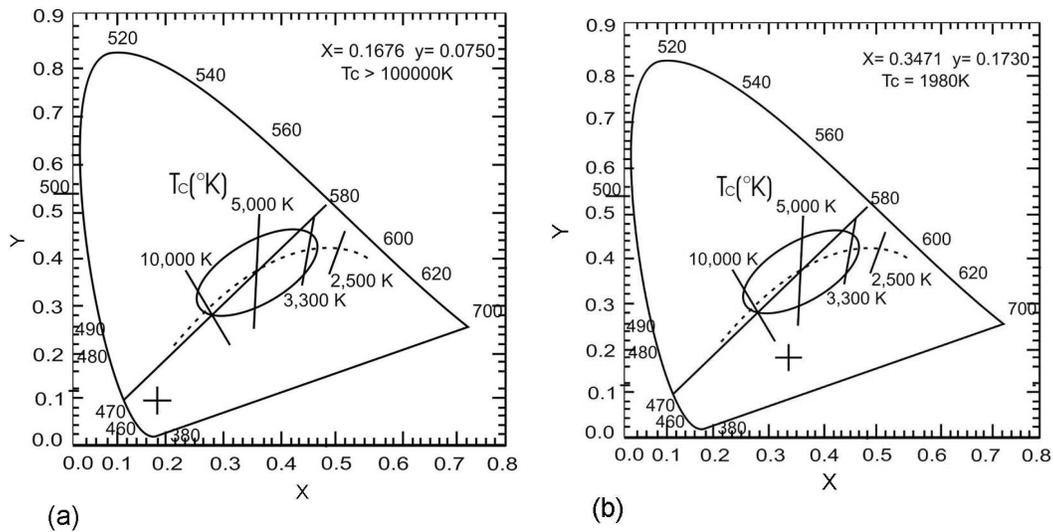


**Fig. 3.** Photoluminescence spectra of MEH-PPV films vs. the thickness ( $d$ ) of the film: “1”:  $d = 200$  nm, “2”:  $d = 400$  nm and “3”:  $d = 1000$  nm.

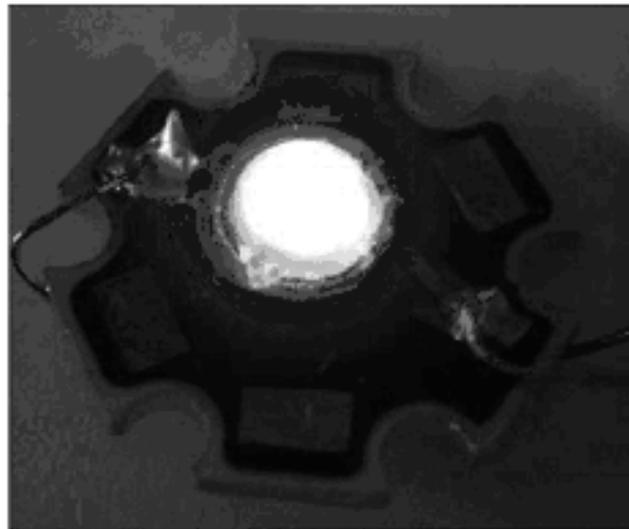
the investigation of their morphological properties by SEM showed that uniform and well-solidified films were obtained, with good adherence and a critical thickness, which is not larger than 400 nm. In case of casting the thicker films, a large density of cracks on the films was observed. Therefore, for further investigation, we controlled the experimental conditions to cover MEH-PPV films with the critical thickness.

The luminous flux of the white LED was measured by using the integrating sphere in the PMS-50 (PLUS) system. Under an applied voltage of 2V (with a 200 mA current), for a thin MEH-PPV film (about 200 nm) that was casted on the LED chip, the emission light exhibited slight blue color. The results of the measured luminous flux is shown in Fig. 4a. The color coordinate corresponds to  $x = 0.1676$  and  $y = 0.0750$ . This proves that the emission light from the LED went through-out without or very weakly exciting the MEH-PPV film. By increasing the thickness of MEH-PPV films up to 400 nm, one can obtain the emission approaching to white light (Fig. 4b). The color coordinate is shown in Fig. 4b corresponds to  $x = 0.3471$  and  $y = 0.1730$ .

The figure 5 shows an image made from a lighting WLED, the supply voltage and the current was, respectively 2V and 200 mA. One problem observed in this WLED is that the lasting time is still short. Within few minute, the yellow band was quenched and the original color of MEH-PPV was bleached. The origin of bleaching of film color and the quenching of the PL yellow band was suggested to be due to strongly heating polymer and the structure decomposition under blue light irradiation. In order to study the effect of quenching process of MEH-PPV film we used the He-Cd laser beam ( $\lambda = 442$  nm) served as excitation for the polymer luminescence. The PL spectra were recorded each 30 s by a cooled CCD, keeping the sample exposed continuously to the 200 mW blue laser beam. The laser spot diameter is around 1 mm, corresponding to a power density is ca.



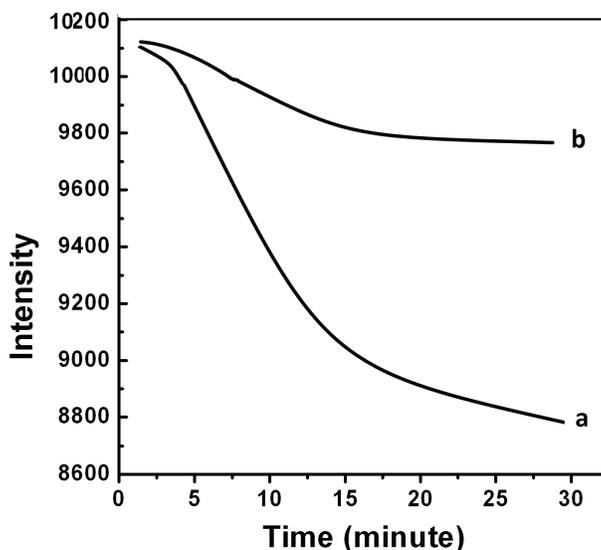
**Fig. 4.** Color coordinate of LED chip coated by a 200 nm (a) and 400 nm (b) thick MEH-PPV films.



**Fig. 5.** Picture of a lighting WLED made by covering a 400 nm thick MEH-PPV layer.

10 W/cm<sup>2</sup>). Fig. 6 presents the plots of the dependence of PL intensity on the exposing time for the samples which were annealed in air and in vacuum at temperature of 120 °C, for 2 h.

From this figure one can see that after 30 minute, for the sample annealed in air, the PL intensity decreased more than 12% and it seemed to be decreasing more. This



**Fig. 6.** The decrease in the PL intensity by exposing time of MEH-PPV films (thickness  $d = 400$  nm) annealed in air (a) and in vacuum of  $\sim 5 \times 10^{-2}$  Pa (b).

film is ageing fast. For the sample annealed in vacuum, the aging occurred in first 15 min exposition, then reached a saturation state. The PL intensity decreased with a considerably small value, i.e. about 0.5%. This demonstrates that quality of the polymers, for MEH-PPV in particular, was strongly affected by the oxygen in the air.

#### IV. CONCLUSIONS

Optical properties of the conjugate polymer as MEH-PPV made by spin-coating with a critical thickness of 400 nm was characterized by absorption and photoluminescence spectroscopy. The results demonstrated that this polymer is suitable for making white light LEDs (WLED). The last was done by casting the MEH-PPV onto the chips of InGaN LEDs. The luminous flux measured on WLEDs in the integrating sphere showed the white light emission was obtained from the combination of inorganic LED and conjugate (MEH-PPV) polymers with an optimal thickness and a high quality. The aging process of MEH-PPV films was found to be strongly dependent post-treatment conditions. Reasonable heat treatment conditions for the MEH-PPV polymers was suggested as in vacuum of  $5 \times 10^{-2}$  Pa at a temperature of  $120^\circ\text{C}$  in , for 2 hour.

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